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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/756,831	01/14/2004	Kiyotaka Murashima	50212-566	2387
20277	7590 05/25/2005		EXAMINER	
MCDERMOTT WILL & EMERY LLP 600 13TH STREET, N.W.			PEACE, RHONDA S	
	ON, DC 20005-3096		ART UNIT	PAPER NUMBER
			2874	
			DATE MAILED: 05/25/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	-				
	10/756,831	MURASHIMA ET AL.	W				
Office Action Summary	Examiner	Art Unit	<u> </u>				
	Rhonda S. Peace	2874					
The MAILING DATE of this communic Period for Reply	ation appears on the cover sheet wi	th the correspondence address					
A SHORTENED STATUTORY PERIOD FO THE MAILING DATE OF THIS COMMUNIC - Extensions of time may be available under the provisions of after SIX (6) MONTHS from the mailing date of this commur - If the period for reply specified above is less than thirty (30) - If NO period for reply is specified above, the maximum statu - Failure to reply within the set or extended period for reply wi Any reply received by the Office later than three months afte earned patent term adjustment. See 37 CFR 1.704(b).	ATION. 37 CFR 1.136(a). In no event, however, may a mication. days, a reply within the statutory minimum of thirt tory period will apply and will expire SIX (6) MON II, by statute, cause the application to become AB	eply be timely filed y (30) days will be considered timely. THS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).					
Status							
application 1) Responsive to communication(s) filed	on <u>14 January 2004</u> .						
	o)⊠ This action is non-final.						
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
4)⊠ Claim(s) <u>1-14</u> is/are pending in the ap 4a) Of the above claim(s) is/are 5)□ Claim(s) is/are allowed. 6)⊠ Claim(s) <u>1-14</u> is/are rejected. 7)□ Claim(s) is/are objected to. 8)□ Claim(s) are subject to restriction	withdrawn from consideration.						
Application Papers							
9) The specification is objected to by the	Examiner.						
10)⊠ The drawing(s) filed on 14 January 200	<u>24</u> is/are: a)⊠ accepted or b)□ o	ojected to by the Examiner.					
Applicant may not request that any objecti	on to the drawing(s) be held in abeyan	ce. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the state of the s	· · · · · · · · · · · · · · · · · · ·						
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim fo a) All b) Some * c) None of: 1. Certified copies of the priority do 2. Certified copies of the priority do 3. Copies of the certified copies of application from the International	ocuments have been received. Ocuments have been received in A I the priority documents have been al Bureau (PCT Rule 17.2(a)).	pplication No received in this National Stage					
Attachment(s)							
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-3) Information Disclosure Statement(s) (PTO-1449 or PT Paper No(s)/Mail Date 5/3/04.	D-948) Paper No(s	ummary (PTO-413))/Mail Date nformal Patent Application (PTO-152) 					

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Information Disclosure Statement

The information disclosure statement (IDS) submitted on 5/3/2004 was filed in compliance with the provisions of 37 CFR 1.97. Accordingly, the information disclosure statement is being considered by the examiner.

Priority

Acknowledgment is made of applicant's claim for foreign priority based on an application filed in Japan on 1/14/2003. It is noted, however, that applicant has not filed a certified copy of the Japanese application P2003-006146 as required by 35 U.S.C. 119(b).

Inventorship

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1, 4, 5, 8, 9, and 12 are rejected under 35 U.S.C. 102(b) as being anticipated by Cole et al (US 6072926).

In reference to claims 1, 4, 5, 8, 9, and 12, Cole et al discloses a method of forming optical waveguide gratings, and the device by which this method can be executed. The method by which Cole et al forms optical waveguide gratings comprises disposing a phase grating mask 30 beside an optical waveguide 40, irradiating the optical waveguide 40 in a longitudinal direction relative to the waveguide 40 during the scanning process with an irradiation means comprising a UV laser light source output 10 and a scanning mirror 20 (Figure 1). Further, Cole et al discloses vibrating the phase grating mask 30 in a longitudinal direction with respect to the waveguide 40, using a piezoelectric stage 50, upon irradiation, and changing the period of vibration of the phase grating mask 30 for each scan of the irradiation point (Figure 1; column 3 lines 26-40 and 53-60; column 5 lines 37-48). In addition, and pertaining to the device claims 5, 8, 9, 12, Cole el at clearly discloses the device for execution of the above-described method of forming an optical waveguide grating (column 3 lines 26-40 and 53-60; column 5 lines 37-48).

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Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 2, 3, 6 and 7 are rejected under 35 U.S.C. 103(a) as being unpatentable over Cole et al (US 6072926).

Pertaining to the claims 2, 3, 6, and 7, Cole et al clearly describes the phase shift of the grating as being highly dependent upon the relative movement of the phase mask in relation to the optical waveguide. Further, Cole et al describes the method as previously described lends great flexibility as variation of the said relative movement will alter the phase shift of the optical fiber, thereby allowing the user to create a fiber to the specification to which they desire (column 3 lines 33-36). Therefore, it would be obvious to one skilled in the art that the above-mentioned method can be carried out with any designated number of irradiation scans from the laser light source. Further, it would also be obvious to one skilled in the art to manipulate relative movement between the phase mask and the optical fiber to produce a diffraction grating with any designated phase shift. Both choosing a irradiation scanning frequency and manipulating the relative movement of the phase mask and the fiber give the user a large degree of freedom in production, so that they may produce an optical diffraction grating that has the ability to be highly specialized to the user's purpose and provide numerous options

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for not only the number of irradiation points on the fiber, but also the phase shift of each irradiated section of the waveguide.

Claims 10, 11, 13, and 14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Cole et al (US 6072926), and further in view of Reid et al (US 6345135).

With reference to claims 10, 11, 13, and 14, Cole et al discloses the method of creating a diffraction grating on an optical fiber, as described above, in addition to a device for implementing the said method, as described above. In addition, Cole et al. further states that optical fibers having such diffraction gratings are key components in many fiber optic and laser system, but makes no specific mention of multiplexer/demultiplexer or optical transmission systems as applications of the above mentioned device or method (column 1 lines 4-8). However, Reid et al discloses an optical reflector comprising a diffraction grating structure that can be incorporated into a wavelength division multiplexer or demultiplexer, and also used within optical telecommunications systems (column 1 lines 15-19; column 3 lines 16-22). It would have been obvious to one skilled in the art to combine the teachings of Cole et al and Reid et al, as diffraction gratings are common components within multiplexer/demultiplexer devices as well as optical transmission systems, and further. as diffraction gratings formed by the above-described method will allow the waveguide to be highly specialized, based upon the preferences of the user, to provide a

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waveguide more well-suited for the specific functions of the multiplexer/demultiplexer device or optical transmission system.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Rondinella et al (US 6591039) describes a method for forming a diffraction grating on a waveguide using a phase mask, ultraviolet light source, and an optical system to reflect the UV light upon the phase mask, where the phase mask is displaced to create an appropriate phase shift. Wang et al (US 6873762) describes a similar device, where the period of the interference pattern along the optical fiber is varied by varying the distance between the fiber and a condenser lens that focuses light from the phase mask onto the optical fiber.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Rhonda S. Peace whose telephone number is (571) 272-8580. The examiner can normally be reached on M-F (8-5).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Rodney Bovernick can be reached on (571) 272- 2344.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Rhonda S. Peace

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> / John D. Led Primary Examiner

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